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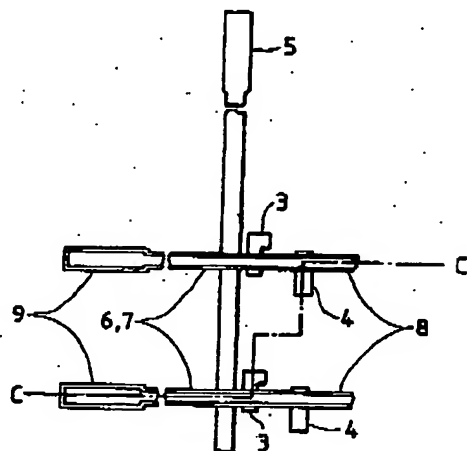
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**(54) Liquid crystal display device and method of fabricating the same**

(57) An object of the present invention is to provide a liquid crystal display device which can be fabricated through simplified processes, provides high product yield, and is excellent in picture displaying characteristic. The liquid crystal display device of the present invention comprises a substrate (1) having thereon a plurality of drain wirings (2), a plurality of gate wirings (8) crossing the plurality of drain wirings (2) in a matrix array, a plurality of thin film transistors disposed in the vicinity of these crossings, and a plurality of pixel electrodes (4) connected to the thin film transistors, respectively, a substrate disposed in opposing relation to the substrate (1), and a liquid crystal layer sandwiched between these substrates. Each terminal portion (5; 9) of the plurality of drain wirings (2) and plurality of gate wirings (8) is constructed with a metallic film covered with a transparent conductive film.

**FIG. 4**

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